

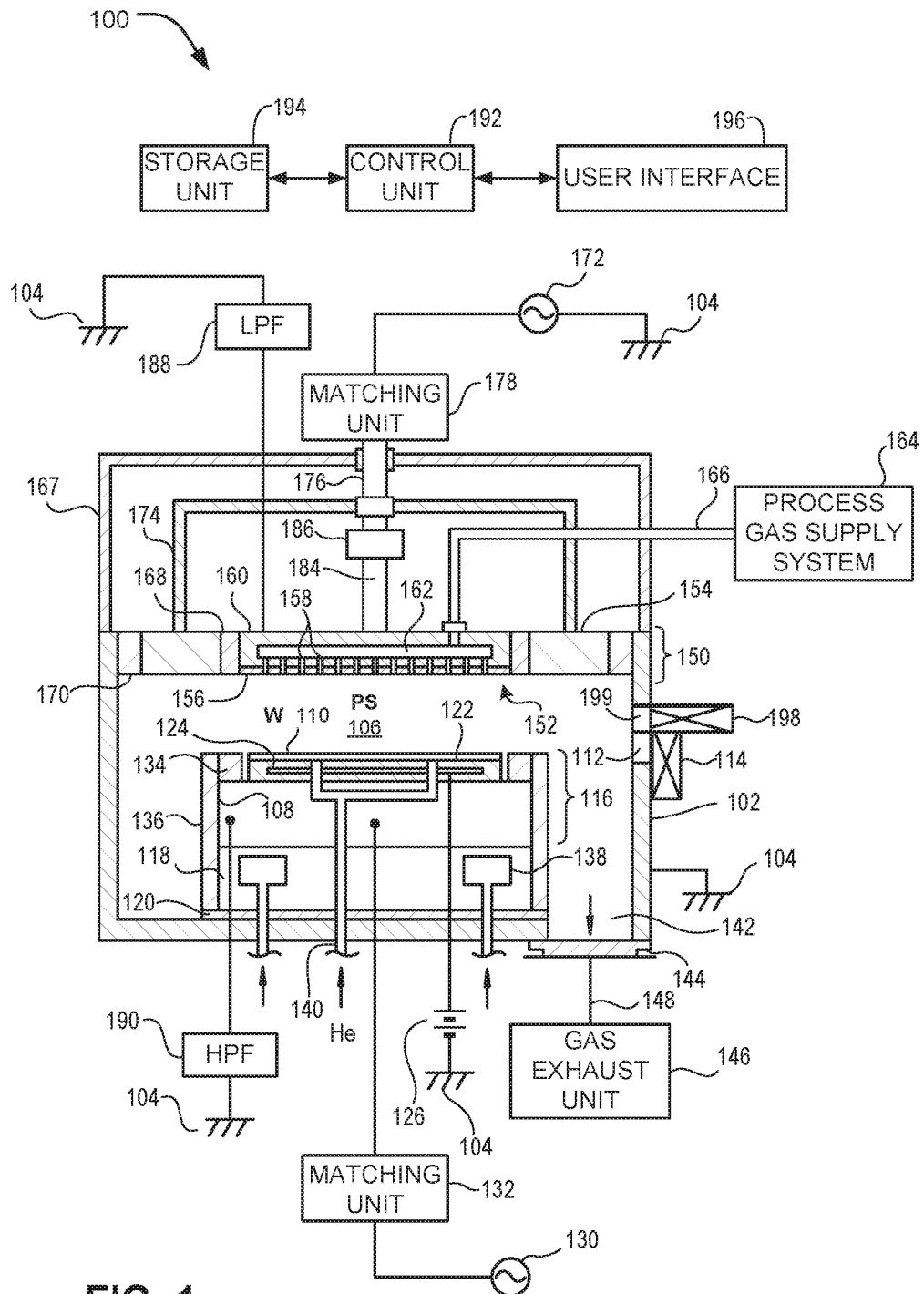


FIG. 1

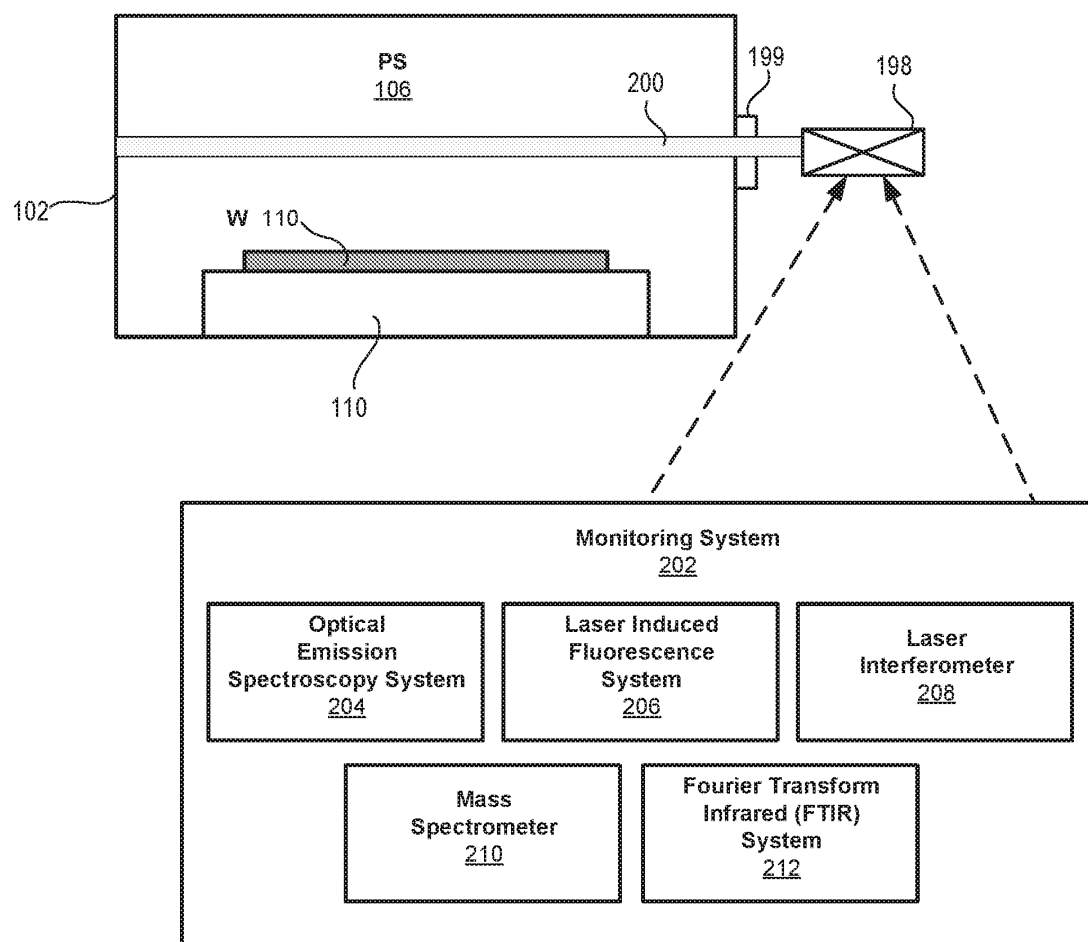


FIG. 2

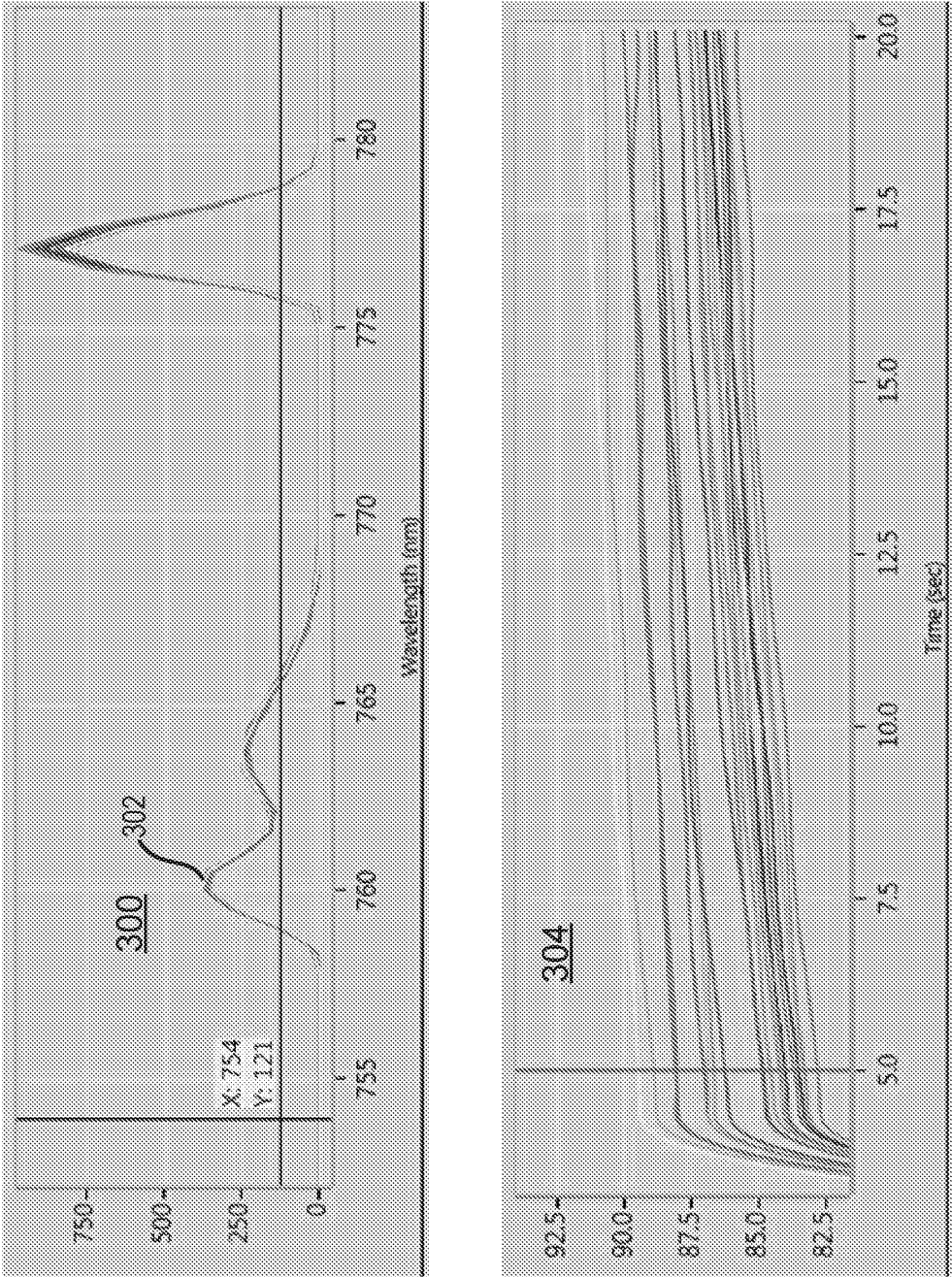


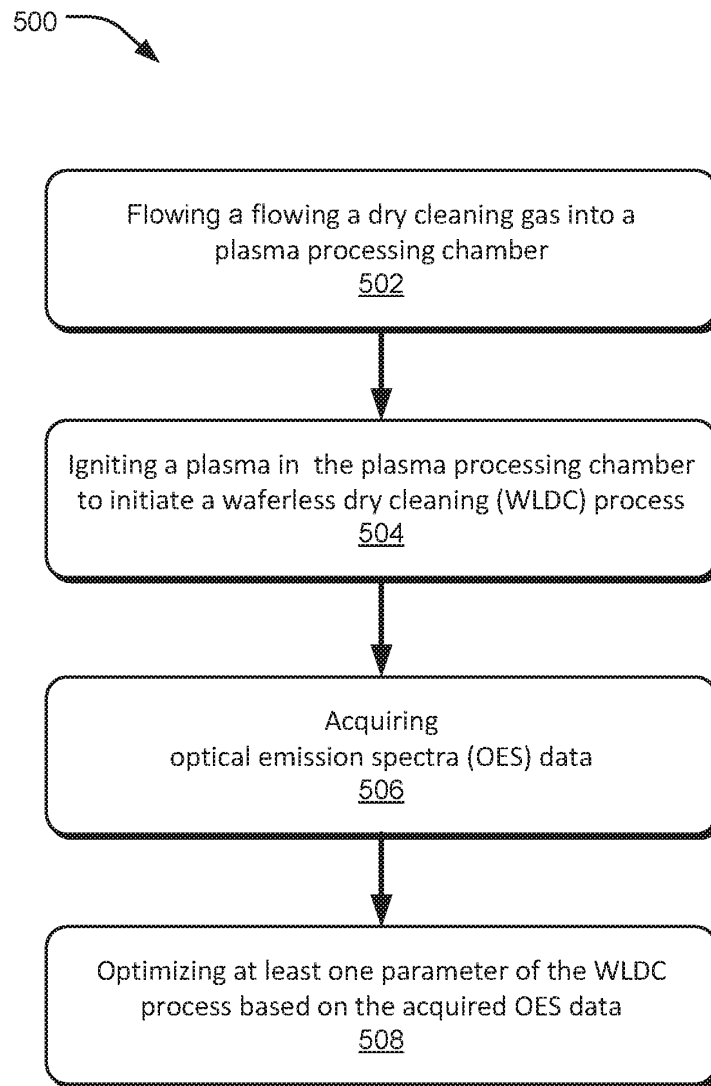
FIG. 3

400



Recipe 402	Step 406	Etch time [sec]	Press		Power [W]		DC			RDC	A-RDC		B.He [Tr]	Temp	ATCC [deg.C]
			[mT]		HF	LF		N2	O2		C4F8	O2		Brine (deg.C)	
WLDC-Via- 4 404	O2 clean 408	20 410	400		200	0	0		1500	50	0	0	0	-10	25, 25
	N2 clean	10	200		700	0	0	480		50	0	0	0	-10	25, 25

FIG. 4

**FIG. 5**

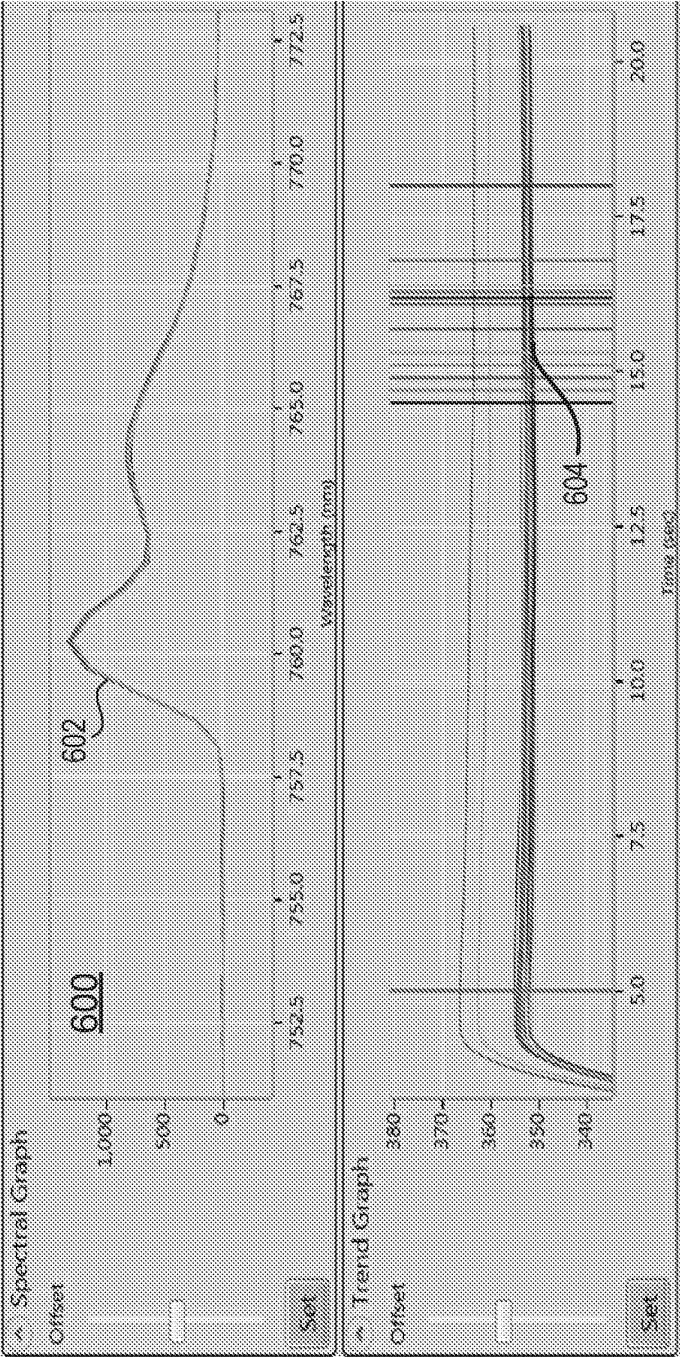


FIG. 6

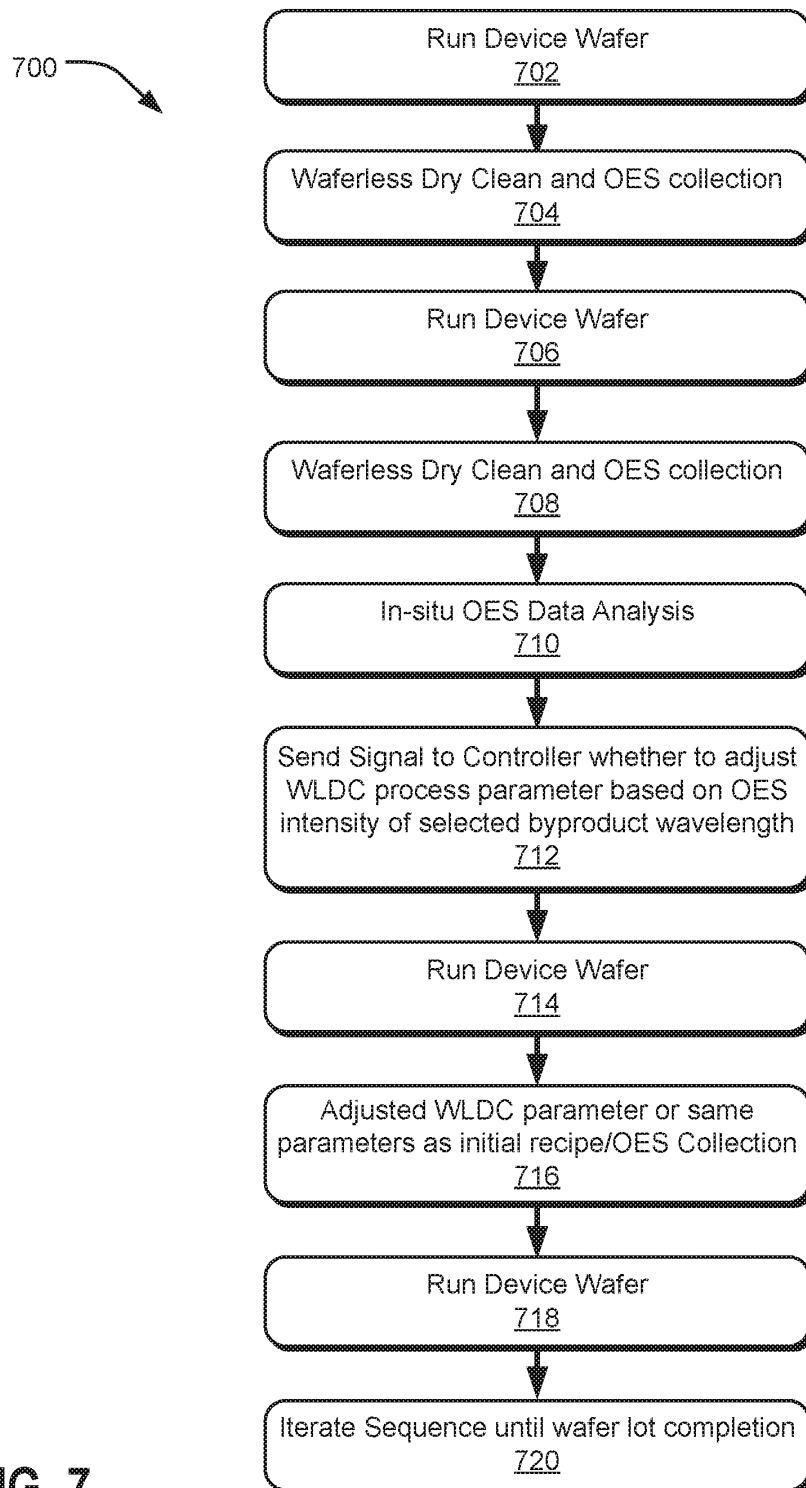


FIG. 7